

HyMARC Seedling: ALD (Atomic Layer Deposition) Synthesis of Novel Nanostructured Metal Borohydrides

Steven Christensen, Noemi Leick National Renewable Energy Laboratory Karl Gross H2 Technology Consulting Svitlana Pylypenko, Margaret Fitzgerald Colorado School of Mines

DOE Hydrogen and Fuel Cells Program 2020 Annual Merit Review and Peer Evaluation Meeting

Project ID #ST143

This presentation does not contain any proprietary, confidential, or otherwise restricted information.

Overview

Timeline and Budget

- Project start date: 9/15/2017*
- Project end date: 3/31/2021
- FY18 DOE funding: \$250k
- FY19 planned DOE funding: \$375k
- FY20 planned DOE funding:
- \$375k
- Total DOE funds received to date: \$1,000,000

*Phase 3 Project Start: 4/1/2020

Barriers

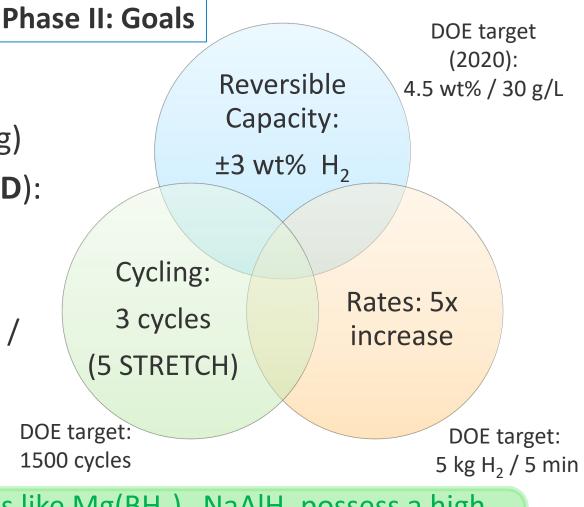
- **D** Durability/Operability
- **E** Charging/Discharging Rates
- **O** Lack of understanding of hydrogen chemisorption

Partners

H2Tech Consulting (cost share) Colorado School of Mines (cost share) HyMARC core team

Relevance: Improve H₂ cycling and rates

- Project objectives: PI
 Improve *reversible capacity* and *rates* (charging/discharging)
- Reversibility (Barrier D):
 Increase cycle life
- *Rates* (Barrier E.):
 - Reduce H₂ charging / discharging time
 - Reduce Operating
 Temperatures



Complex metal hydrides like Mg(BH₄)_{2,} NaAlH₄ possess a high hydrogen storage capacity, but insufficient charging/discharging rates and cyclability for DOE targets.

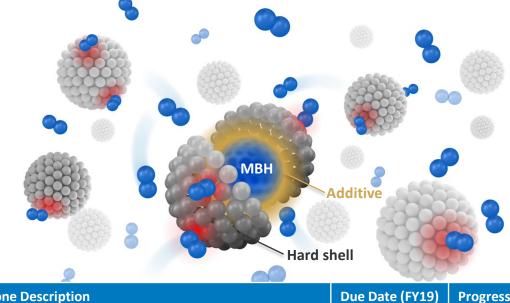
Approach: Coatings by Atomic Layer Deposition (ALD)

<u>Concept:</u> Improve reversible capacity and rates by materials with:

- 1) Durable nanostructured phase
- 2) Chemical additives that enhance reaction rates

How: ALD coatings that:

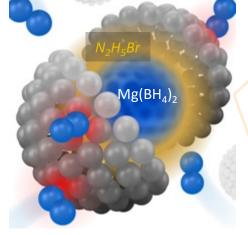
- **Protect.** Hard-permeable coating to retain nano-hydride for cyclability.
- **Catalyze.** Thin layer of additives that enhance rates.



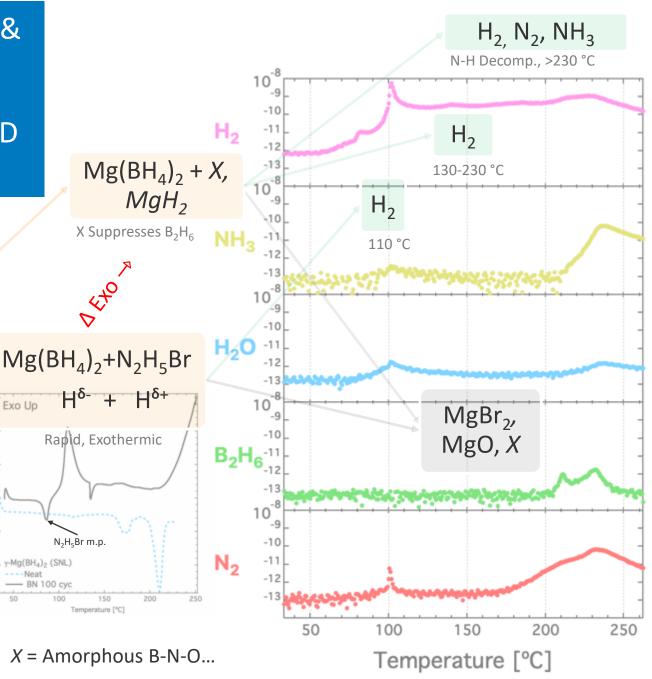
Milestone Description	Due Date (FY19)	Progress
Determine the discharging reaction mechanism	Q2	100 %
Determine charging rates/cyclability of neat Mg(BH ₄) ₂	Q1	100 %
Determine the charging reaction mechanism	Q3	100 %
Characterize coatings with advanced microscopy	Q4	100 %
Go/No-Go (GNG): Three H_2 cycles at 3 wt% H2 + 5x improved charging. (Conditions: 250°C, 120 bar H_2)	Q4	100 %

ALD coatings on $Mg(BH_4)_2$ developed in FY18 improved discharge rates and showed potential for charging and cyclability.

Accomplishments & Progress (A&P): Desorption mechanism for ALD BN/Mg(BH₄)₂



- Rapid H₂ discharging results Mg(BH₄)₂ + N₂H₅Br
- N₂H₅Br is a product of 'boron nitride' ALD
- Reaction driven by:
 - Heterolytic cleavage of B-H, N-H
 - Exothermic
- Irreversible Mg-O-Br-B-N products result

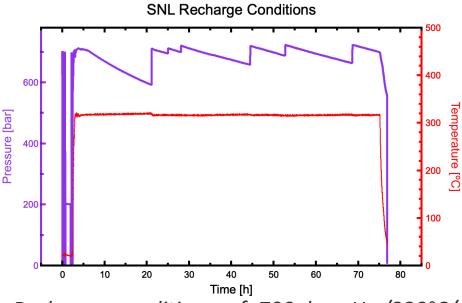


A&P: High pressure recharge of ALD-Mg(BH₄)₂

- High Pressure Recharge / Sandia National Lab:
 - Year 1 materials: ALD on $Mg(BH_4)_2$: $TiO_2-Al_2O_3-CeO_2$, $Pd-Al_2O_3$, BN, TiN
 - Pre-desorbed to high temperature
 - Recharge: 700 bar H₂ / 320 °C / 72 h
 - All 4 samples recharged at the same time

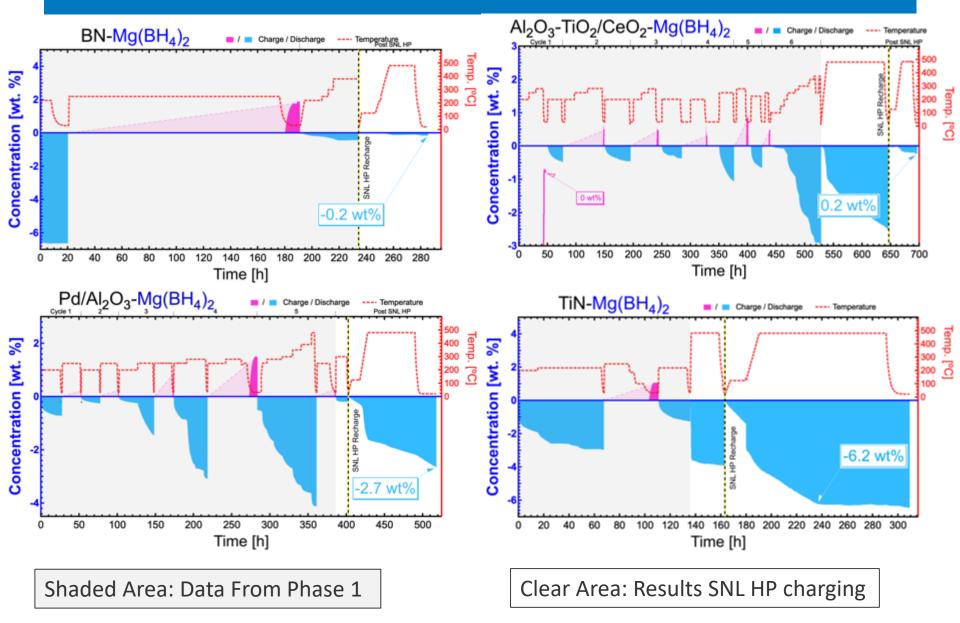


Sandia high pressure charging apparatus can reach up to 1000 bar H_2 and 400 °C.



Recharge conditions of 700 bar $H_2/320^{\circ}C/$ 72h should not result in $Mg(BH_4)_2$ without active <u>additives</u> present.

A&P: Post High-Pressure Recharge Desorption



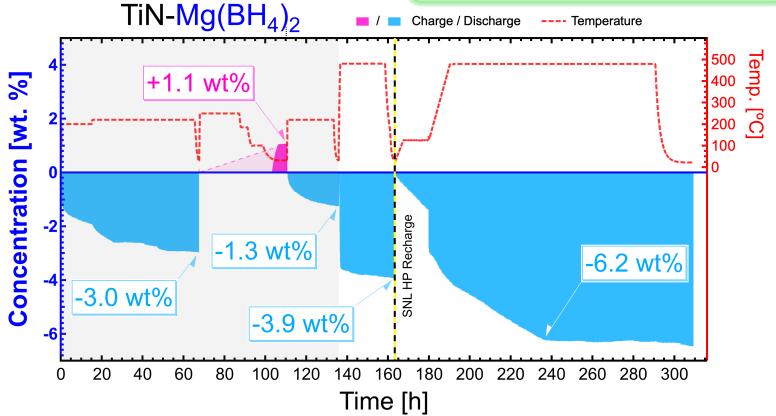
A&P: Analyzing TiN/Mg(BH₄)₂ results

- Mg(BH₄)₂: 14.9 wt% H₂
- (-3.0) + (+1.1) + (-1.3) + (-3.9) = -7.1 wt% H₂
- TiN/Mg(BH₄)₂: 7.1 / 14.9 = 50%
 Capacity
- Reversibility TiN/Mg(BH₄)₂ = 6.2 wt%

- @ 6.2 / 7.1 = 87 % efficiency! (?)
- Desorbed H₂ >> Binary hydrides (e.g. MgH₂ at 7.6 wt%)

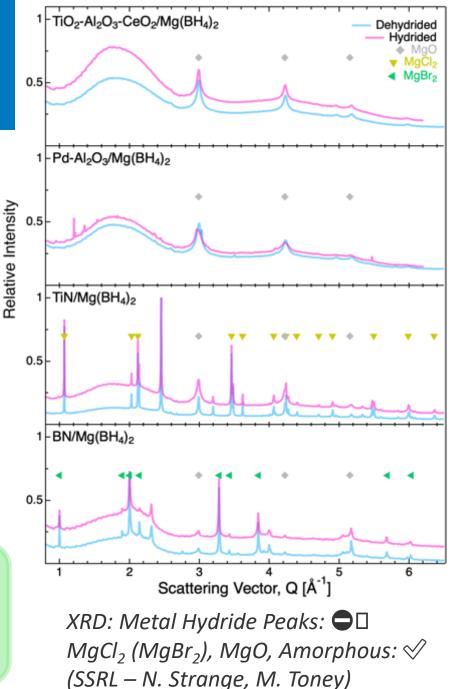
ALD titanium nitride (TiN) is a promising new hydride additive!

NREL | 8



A&P: Reversibility via TiN coating shows a path to cycling (and *Phase 3*)

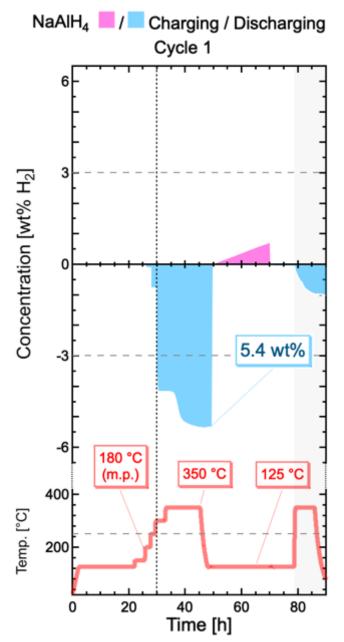
- No crystalline Mg(BH₄)₂
 (or other hydrides)
- Lots of irreversible MgCl₂,
 MgO, etc.
- Rates Needed 480 °C and it still took a long time
- TiN/Mg(BH₄)₂ reversibility at high cycling efficiency
- GNG & Phase 3: Find the metal hydride that TiN will enable cycling



A&P: Unmodified 'Neat' NaAlH₄ has Poor Rates

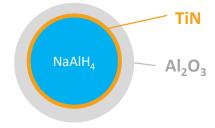
- Without additives (e.g. Ti) NaAlH₄ kinetics are too slow:
 - 5.4 wt% H₂ desorbed only after heating > 300 °C
- Absorption thermodynamics requires lower temperatures
 - Very little reversible cycling capacity observed
- <u>Can an ALD TiN get NaAlH₄</u> <u>to cycle?</u>

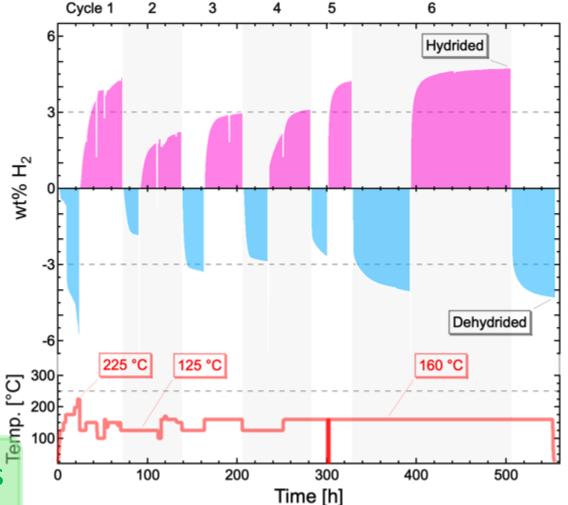
Neat NaAlH₄ from Sigma Aldrich



A&P: H₂ cycling ALD-NaAlH₄ surpasses Phase 2 goal

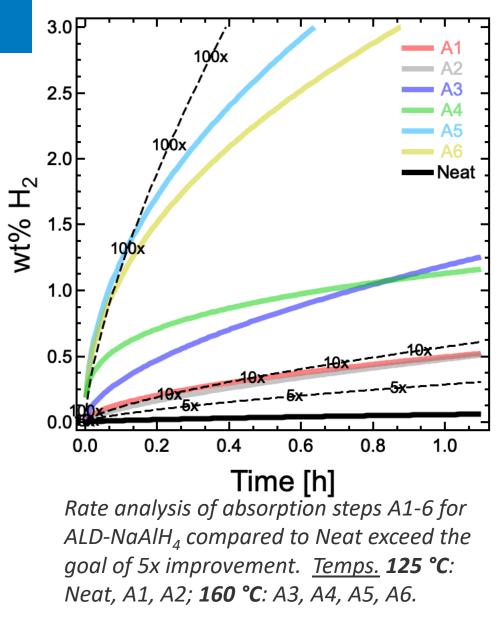
- PCT cycling:
 - 120 bar H₂
 - 225 °C: -5.7 wt%: Full theoretical capacity
 - 160 °C (from 350 °C)
 - 6.5 cycles
- Reversibility:
 - -3.6/+3.8 wt% avg.
 - -4.3/+4.8 wt% best ∞
- Goal: 3 wt% @ 3 cycles[†]



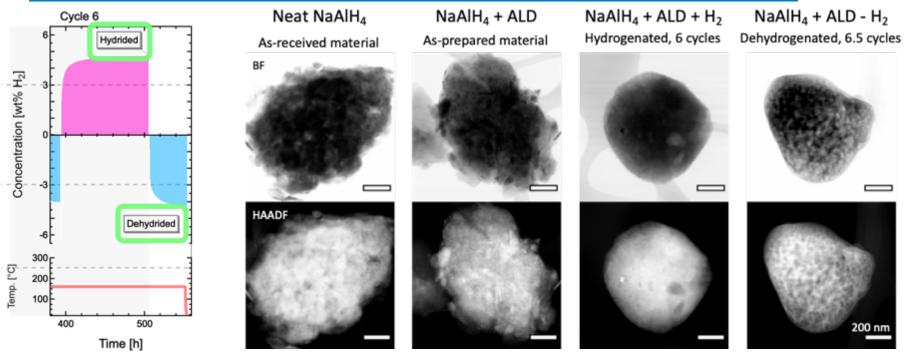


A&P: Rates for ALD-NaAlH₄ exceed Phase II Goal

- Power Law Fits to H₂ absorption rate *v*:
 - $\mathbf{v} = \mathbf{k}[H_2]^p$
 - Fitting for first 0.5 h
- Scalar multipliers to rate law of neat NaAlH₄
 - 5x, 10x, 100x
- ALD coatings improve Absorption rates by <u>10-</u> <u>100x</u>



A&P: Smooth, clean morphology evolves from cycling ALD-NaAlH₄



TEM

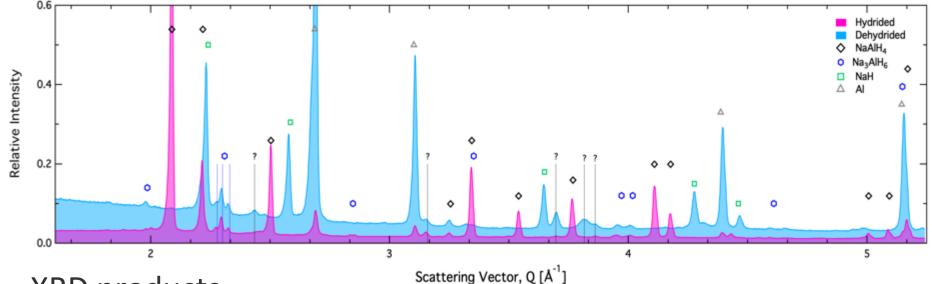
- Desorption 1 > 180 °C (melting point)!
- Cycling \rightarrow smooth morphology
- <u>Particle size: 100s of nm</u>, low particle agglomeration

XRF (not shown)

- Neat NaAlH₄, Ti? No
- Ti on ALD-NaAlH₄?
 Yes!

No detectable Cl

A&P: Efficient Cycling ALD-NaAlH₄ with high reversibility



XRD products

- Dehydrided: Rxn {2}
- Hydrided: Rxn {1}
- <u>No Cl products</u> (e.g. NaCl)
- Reversibility: <u>80-85%</u> <u>of 5.6 wt%</u> Cycling {1} + {2}

NaAlH₄ (7.5 wt% H_2 / 3.7 + 1.9 = 5.6 wt% reversible)

	Reaction	wt% H ₂ (theoretical)	Sample	XRD	wt% H ₂ (measured)
{1}	NaAlH ₄ ≓ ⅓Na ₃ AlH ₆ + ⅔Al + H ₂	3.7	Hydrided	NaAlH₄; Al, Na₃AlH ₆ (trace)	+4.8
{2}	Na ₃ AlH ₆ \rightleftharpoons NaH + Al + 3/2H ₂	1.9	Dehydrided	NaH, Al; NaAl ₃ H ₆ (trace)	-4.3
{3}	$NaH \Rightarrow Na + \frac{1}{2}H_2$	1.8	No	No Na	

Collaboration and Coordination

• H2 Technology Consulting LLC, prime partner, subcontractor, industry



- Quantitative PCT measurements; Subject matter expertise
- Colorado School of Mines, Chemistry Department, subcontractor
 - Advanced materials characterization: atom probe tomography, TEM composition mapping
- HyMARC EMN, DOE FCTO
 - SNL: Nanostructured Mg(BH₄)₂, Subject matter expertise; high pressure experiments
 - NREL: Materials characterization, equipment, facilities, subject matter expertise
 - SLAC: X-ray scattering and spectroscopy
 - LLNL: Theory
 - PNNL: Advanced materials characterization; Subject matter expertise
- Forge Nano, ALD manufacturing company
 - Potential industry partner, letter of support







Technology Transfer Activities

- Provisional patent: "Nanostructured Composite Metal Hydrides", USPTO Application No. 62/507,354 was converted to a non-provisional patent USPTO Application No. 15/982,232.
- Pursuing potential partners for ALD scale-up (ForgeNano)
- Identifying other applications where this technology would solve technical problems

Remaining Challenges and Barriers: How good is ALD-NaAlH₄?

Rates:

- ALD-NaAlH₄ rate is an excellent start with efficient **Ti loading**
- A 10x increase from current levels is required for the **DOE** charging target

Reversible Capacity:

- ALD-NaAlH₄ Reversibility Capacity is exceptional
- \geq 5 wt% H₂ is needed for a pathway to technology

Conventional balled milled Ti additives increase rate at the cost of reversible capacity:

 $NaAlH_4 + TiCl_3 \Rightarrow NaCl + Ti + NaAlH_4...$

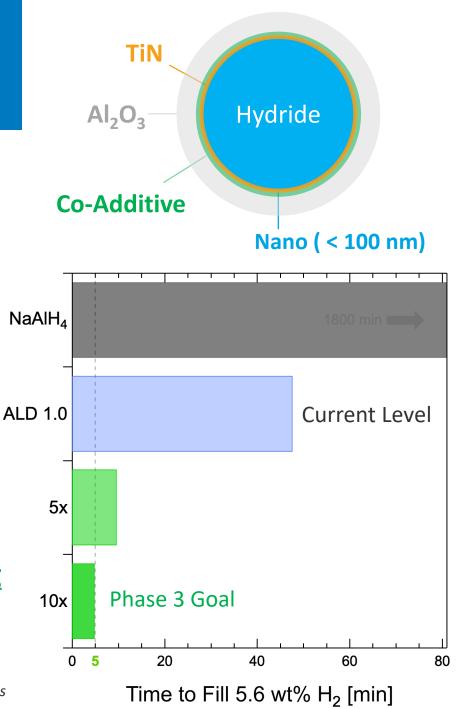
Data in figure adapted from: "Effect of Ti-catalyst content on the reversible hydrogen storage properties of the sodium alanates", G. Sandrock, J Alloys Compd, 339 (2002) 299.

Ti Additives: Ball Milled & ALD 60 6 (5.6 wt% Reversibility) 50 5 Capacity Japac 40 ALD Capacity sate [wt% H₂ 30 ALD 20 Rate 10 1 0 2 3 5 0 6 mol% TiCl₃

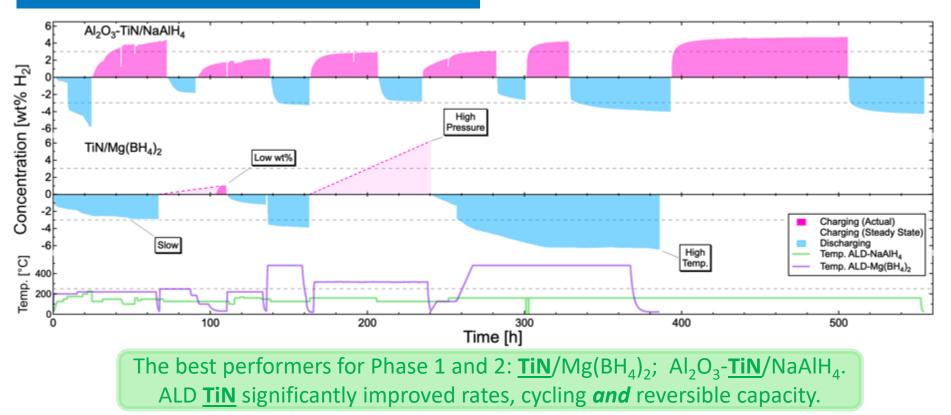
Proposed Future Work: Increase Rates / Capacity

- Co-Additives: Ti + Fe*
 - Increase Rate > 2x
 - Decrease Temperatures
 - *Fe, Ni, Ce, Zr, Pd...
- Nano-size Hydride
 - Increase Rate > 5x+
 - Increase reversible capacity by control of reaction pathways
- Al₂O₃ Coating
 - Improve Cycling, Handling
 - ALD Al₂O₃ passivates w/o loss in capacity

Any proposed future work is subject to change based on funding levels



Summary



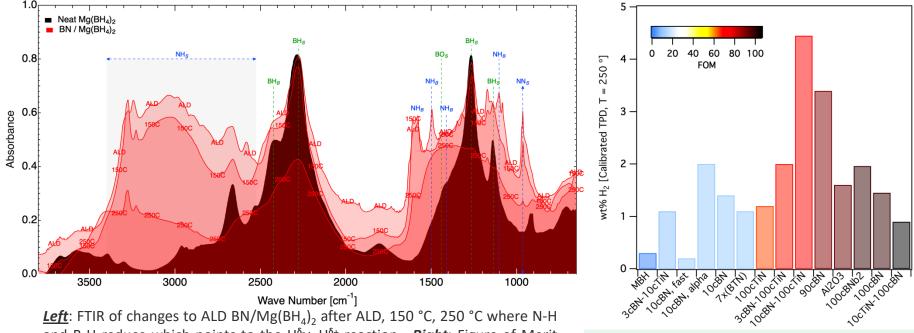
Go/No-Go Phase 2

- ±<u>3 wt% H₂ reversible capacity, 3 cycles</u>
- <u>5-fold (5x)</u> improvement of the absorption kinetics.
- Operability: ≤ **250** °C, ≤ **120 bar H**₂
- **<u>STRETCH</u>** 5 cycles, ± 3 wt% reversibility.

✓ <u>Surpassed</u>
✓ <u>Surpassed</u>
✓ <u>Met</u>
✓ <u>Surpassed</u>

A&P: Responses to Previous Year Reviewers' Comments

- Previous year AMR reviews emphasized the need to understand the ALD 'BN' / $Mg(BH_4)_2$ discharging mechanism and pointed to:
 - Potential reactions with Mg(BH₄)₂ and ALD precursors
 - Spectroscopy to probe species like N-H, B-H
 - Systematic studies of ALD coatings on Mg(BH₄)₂
- In response, over twenty new materials were synthesized and characterized with NMR, IR, XRD, TPD, and microscopy which resulted in the 'desorption mechanism' summarized in slide 5. Some highlights are given below.



<u>Left</u>: FTIR of changes to ALD BN/Mg(BH₄)₂ after ALD, 150 °C, 250 °C where N-H and B-H reduce which points to the H^{δ -}+ H^{δ +} reaction. <u>*Right*</u>: Figure of Merit (FOM) ranking potential of gravimetric penalties of ALD coatings to wt% H₂ release. FOM does not show a dependence film thickness (BN, TiN cycles) which supports the H^{δ -}+ H^{δ +} reaction.

FOM = (BNcycles) +

 $\rho_{TiN}GPC_{TiN}$

(TiNcycles)

Thank You

www.nrel.gov

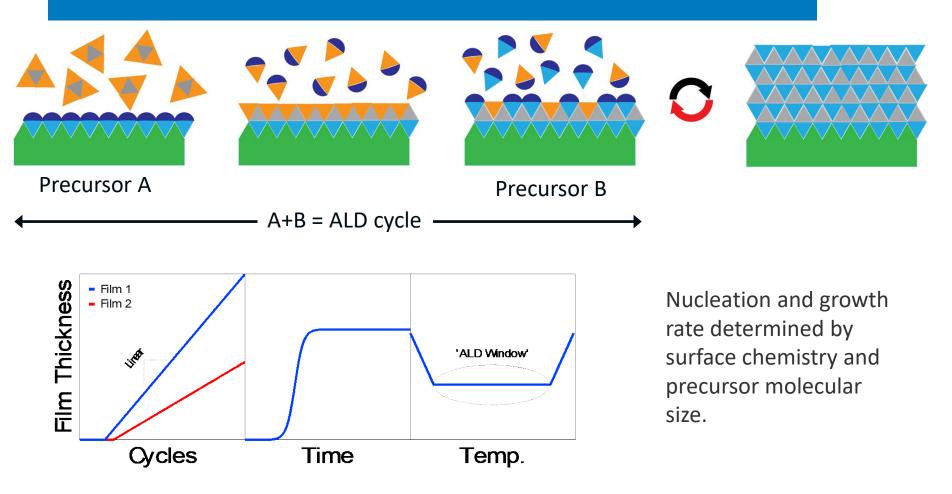
Publication Number

This work was authored [in part] by the National Renewable Energy Laboratory, operated by Alliance for Sustainable Energy, LLC, for the U.S. Department of Energy (DOE) under Contract No. DE-AC36-08GO28308. Funding provided by U.S. Department of Energy Office of Energy Efficiency and Renewable Energy, Fuel Cell Technologies Office. The views expressed in the article do not necessarily represent the views of the DOE or the U.S. Government. The U.S. Government retains and the publisher, by accepting the article for publication, acknowledges that the U.S. Government retains a nonexclusive, paid-up, irrevocable, worldwide license to publish or reproduce the published form of this work, or allow others to do so, for U.S. Government purposes.



Technical Back-Up Slides

Atomic Layer Deposition



Operating principles:

- ALD: sequential, self-limiting reactions at a surface
- Linear growth rate, saturating precursor adsorption, temperature-defined process window